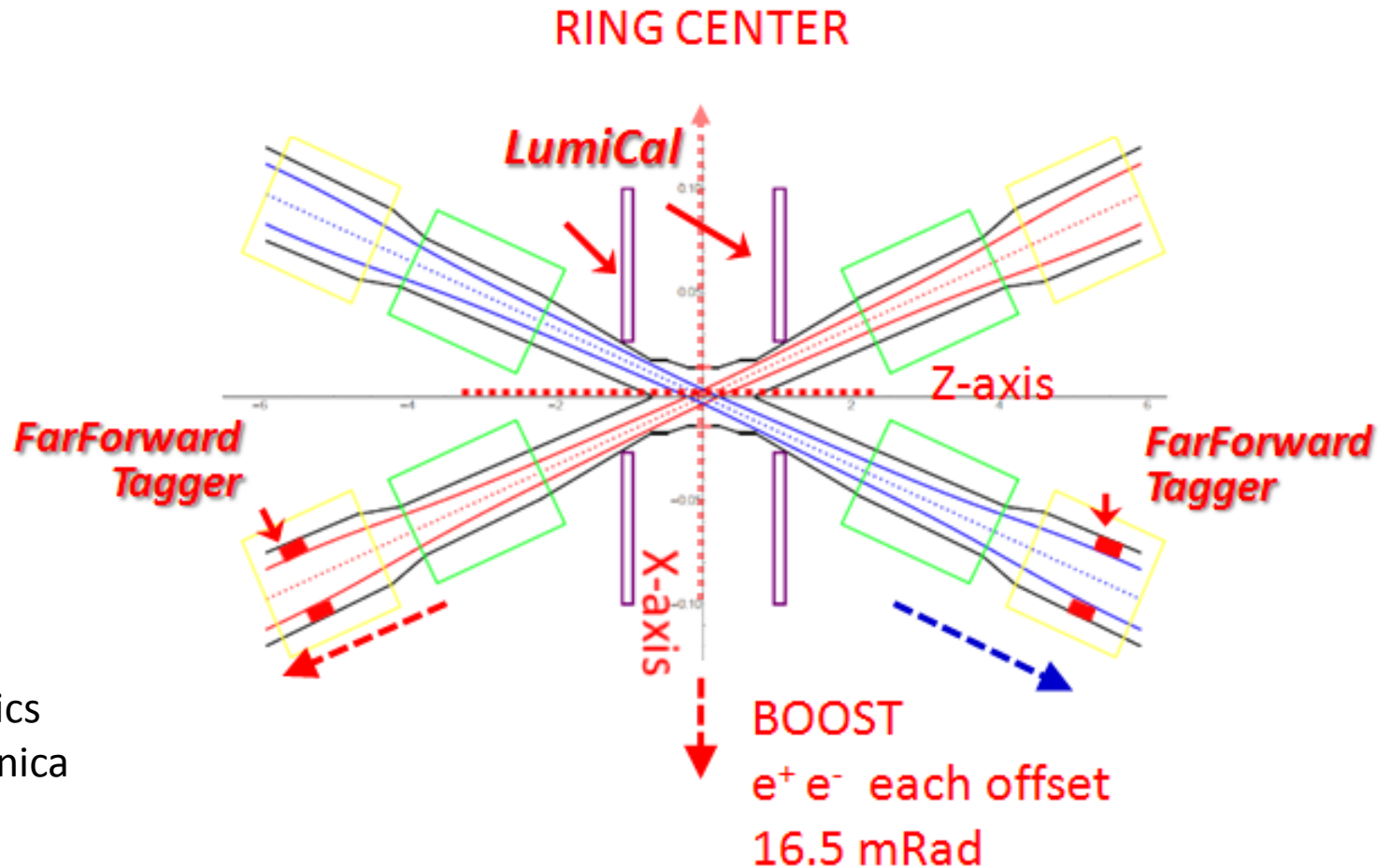


Geometry and cooling for the Lumi detector in MDI



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<https://indico.ihep.ac.cn/event/12324/session/1/contribution/3>

Progress and perspectives

- **Bhabha cross section for Z pole :**
reference to Z-pole, theoretical **BHLUMI** calculation done
beam-pipe $\phi \sim 28 \text{ mm}$
→ Bhabha $\theta_{\min} < 30 \text{ mRad}$ → $\sigma(\text{Bhabha}) > 50 \text{ nb}$ ✓
 - **GEANT study for luminosity $\delta L/L \sim 10^{-4}$**
beampipe material → multiple scattering, EM shower
beampipe shape, detector position → spatial resolution ✓
 - **LumiCal Geometry and Mechanics**
Si-ladder for electron $\delta\theta \sim 1.5 \mu\text{Rad}$ resolution
→ Si-wafer surrounding beampipe, Z-position measurement
LYSO Calorimeter tagging beam scattered electron/photon
→ *Flange details and geom NOT yet optimized*
- *R&D migrating to hardware and electronics*

Luminosity measurement

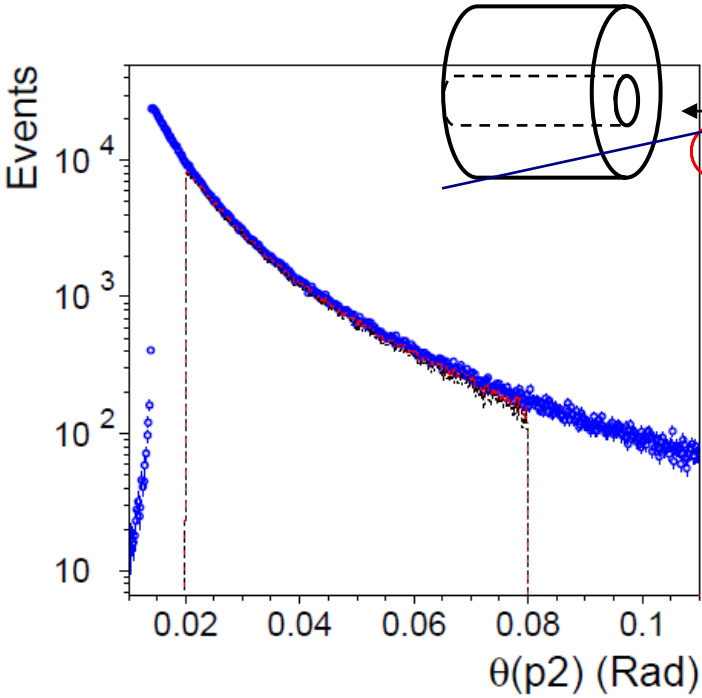
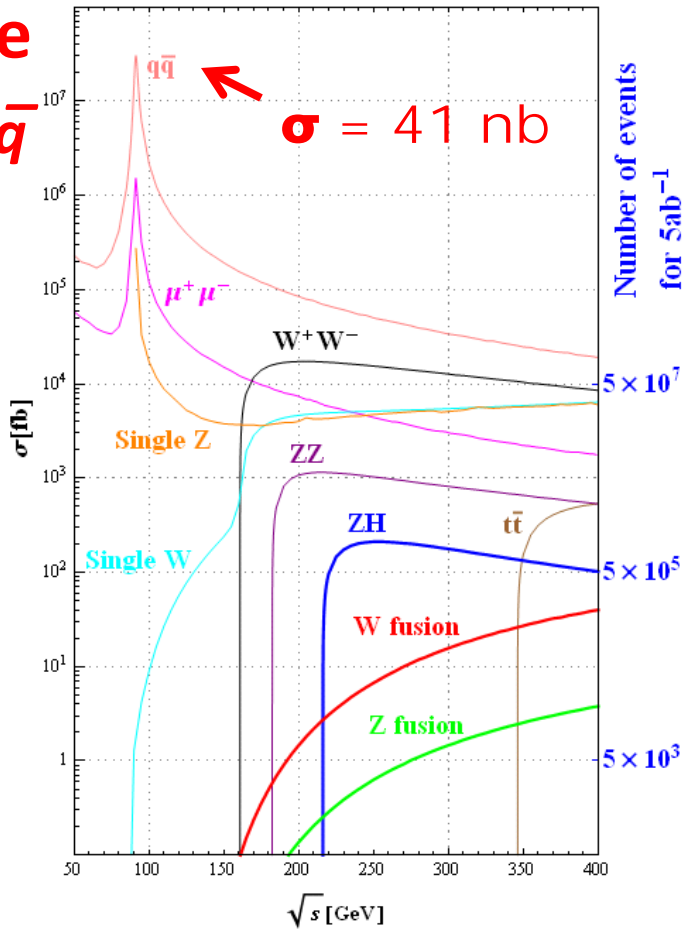
- **Reference to Z-lineshape**

$$e^+e^- \rightarrow Z \rightarrow q\bar{q}$$

- **Luminosity of e^+e^- collisions**

reference by QED Bhabha elastics scattering
theoretical precision < 0.1 %

$$e^+e^- \rightarrow e^+e^-$$



$$\mathcal{L} = \frac{1}{\epsilon} \frac{N_{\text{acc}}}{\sigma^{\text{vis}}}$$

$$\sigma = \frac{16\pi\alpha^2}{s} \left(\frac{1}{\theta_{\text{min}}^2} - \frac{1}{\theta_{\text{max}}^2} \right)$$

Bhabha detection

- $e^+e^- \rightarrow e^+e^-$ elastics scattering

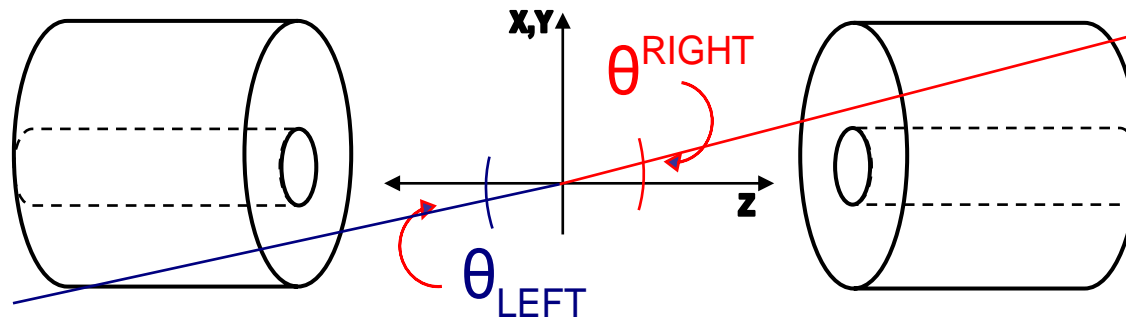
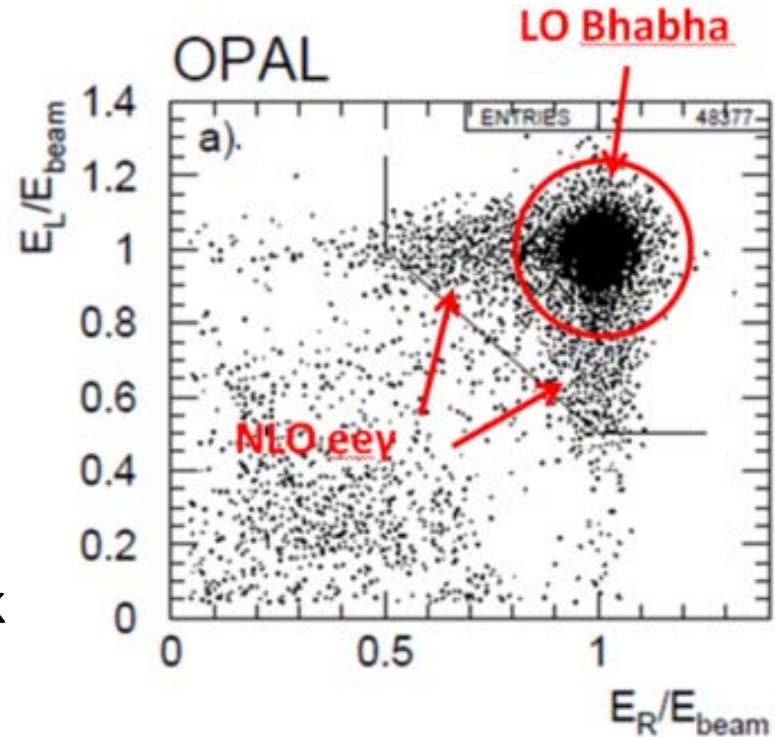
Event signature

1. $E(e^\pm) = E_{\text{beam}}$
2. e^+, e^- Back-to-Back

- **NLO $e^+e^- \rightarrow e^+e^-\gamma$**

$\sim 1\%$ events

1. e^+, e^- approximately Back-to-Back
2. one electron $E' < E_{\text{beam}}$
3. Detector e/γ ID, spatial resolution



$$\Delta\theta \equiv \theta_{\text{RIGHT}} - \theta_{\text{LEFT}}$$

Luminosity precision

Dominant systematic error

$$\delta L/L \sim 2 \delta\vartheta/\vartheta_{\min}$$

For a precision of $\delta L/L < 10^{-3}$

LumiCal at $z = \pm 1$ m,

ref: $\theta_{\min} = 30$ mRad eq. $r = 30$ mm

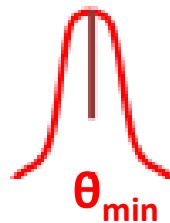
$\rightarrow \delta\vartheta = 15$ μ Rad eq. $dr = 15$ μ m

Error due to offset on Z

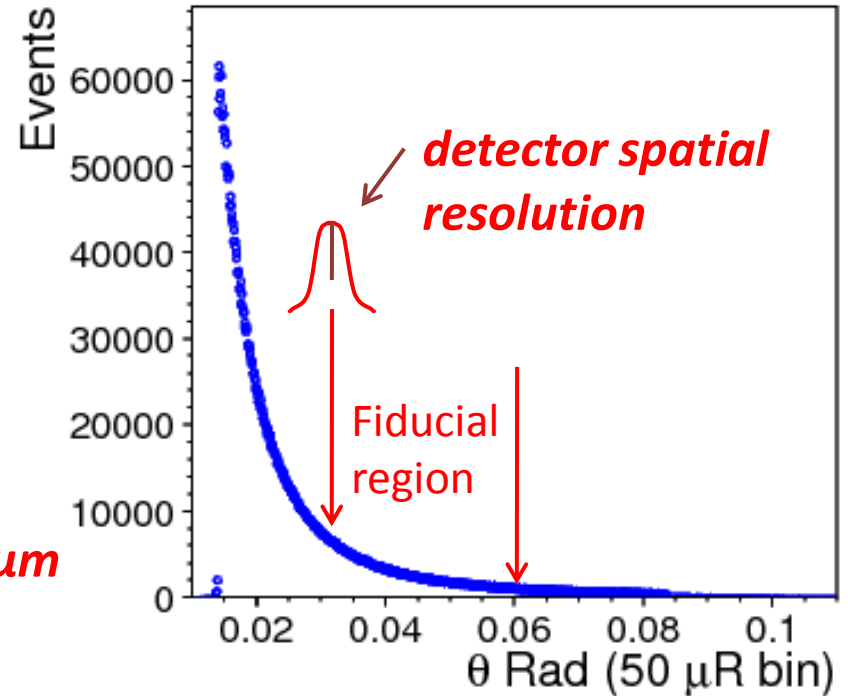
assum. 0.1 mm on $z \rightarrow dr = \delta R \times \vartheta = 3$ μ m

LumiCal design goal:

- Spatial res. narrow
- “Standard error of the mean”
on θ_{\min} : $\sigma/\sqrt{N} < 15$ μ Rad



Bhabha ϑ -angle distribution

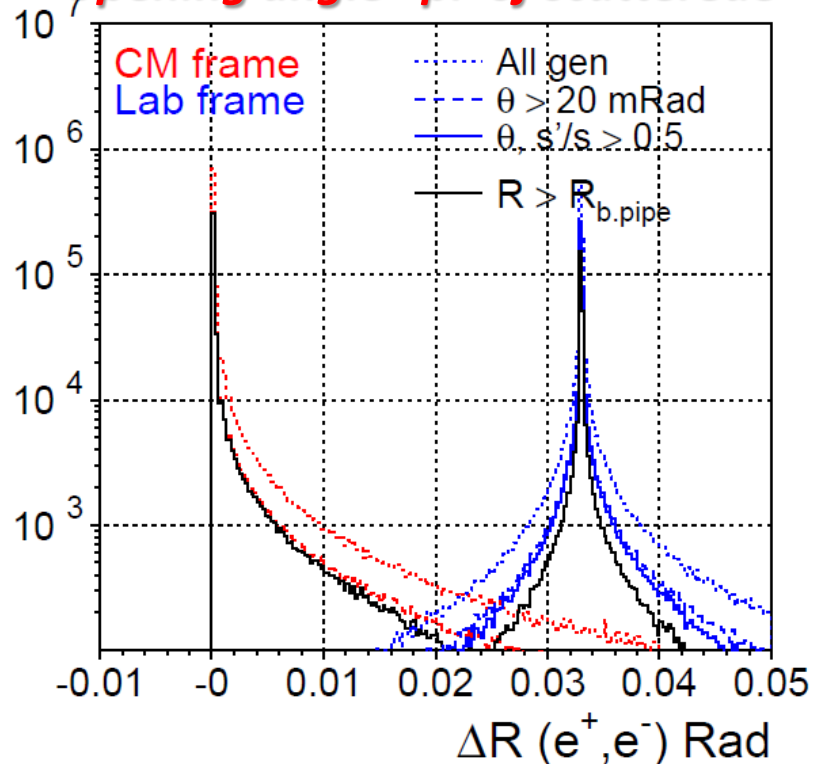


offset of fiducial edge
to “the mean on θ_{\min} ”
 \rightarrow **LUMINOSITY error**

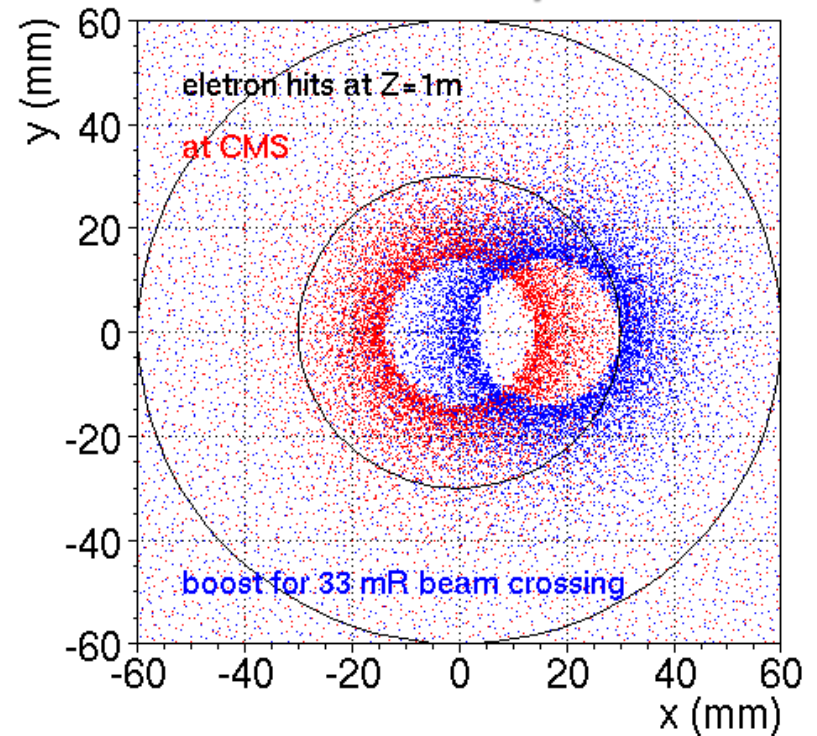
Bhabha back-to-back boosted by 33 mRad beam crossing

- Bhlumi electrons boosted for the 33 beam crossing by ~ 16.5 mRad to +x direction
- Compared for Bhabha selection conditions

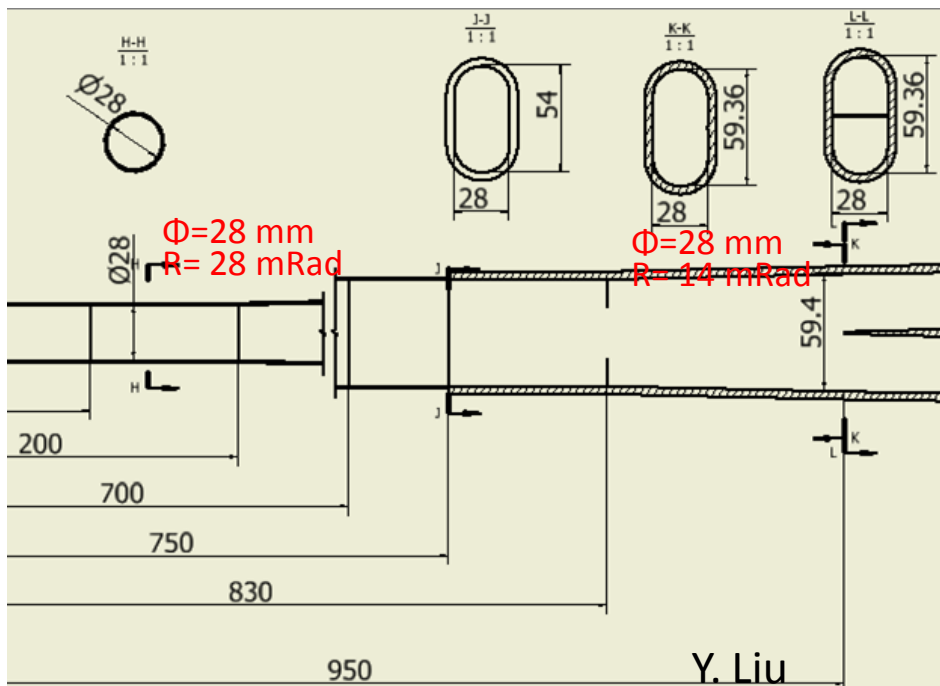
Opening angle $-\pi$ of scattered e^+e^-



Bhabha at detector plane $Z=1m$

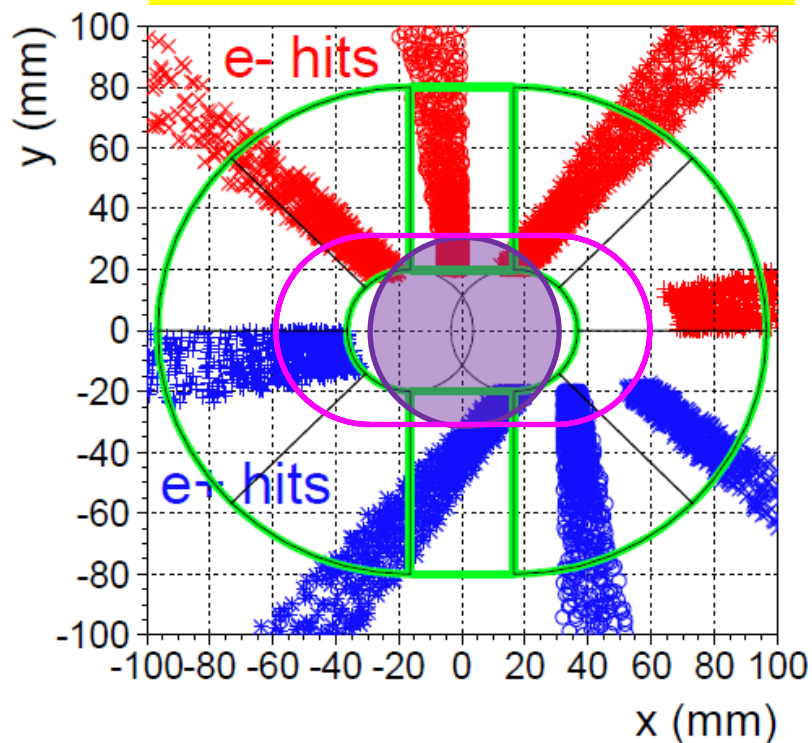


Bhabha cross section



(BHLUMI, boosted for 33 mRad beam crossing)

X-Y hits at Z = ± 1 m



beampipe, $r = 30$ mRad (vertical) $\rightarrow \sigma(\text{Bhabha}) \gtrsim 50$ nb

($r = 30$ mm @ $z = 1$ m)

CMS 10 ~ 80 mRad		LAB detect ONE electron		LAB detect both electrons	
BARE1		off beampipe full phi coverage	off beampipe cut off ± 30 mm	off beampipe full phi coverage	off beampipe cut off ± 30 mm
Nevents	457232	102535	20277	29194	19216
Xsec (nb)	1168.3	262.0	51.81	74.60	49.10

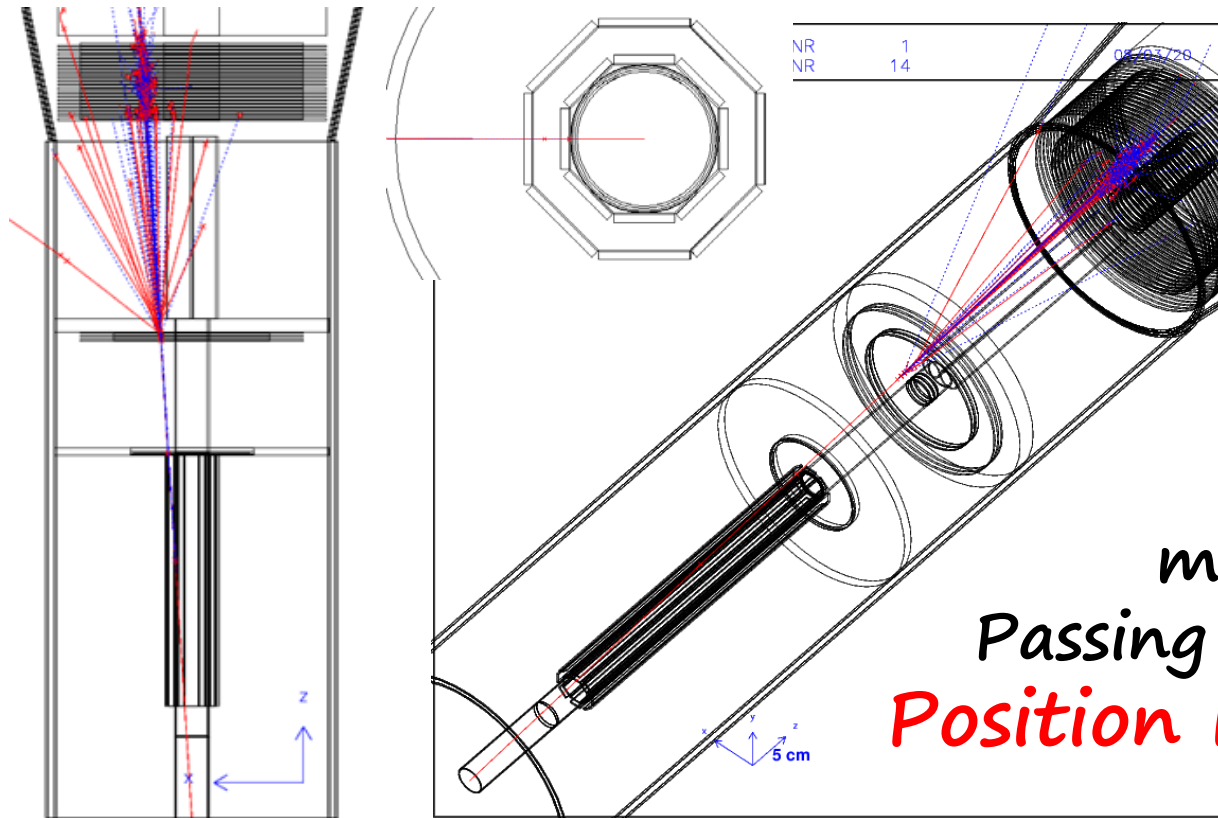
Si octagon wafers surrounding beampipe

Si-ladders surrounding the beampipe

→ minimized smearing by multiple scattering/shower

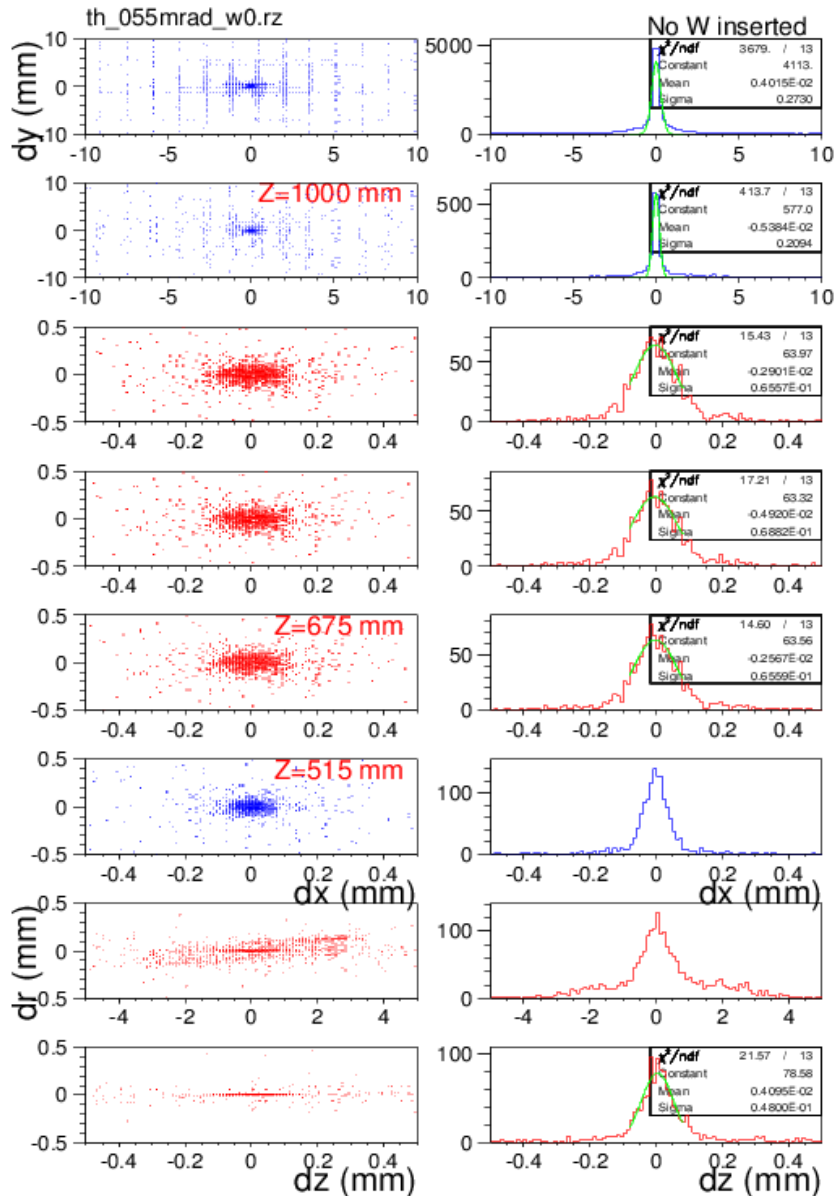
Electron traversing 1 mm thick Al beampipe

@30 mRad, $Z = 0.5$ m, dZ traversing beampipe = **33 mm**



GEANT
multiple scattering
Passing 1 mm beampipe
Position RMS = 50 μ m

Position(Hits) – Electron shower



Piled up of 50 GeV electron shower hits

Front 2 Si-layers of Q-pole LumiCal

Pileup of shower ~ 1 mm resolution

Three Si layers at $Z > 670$ mm

NO Tungsten layers $\sigma = 65$ μm

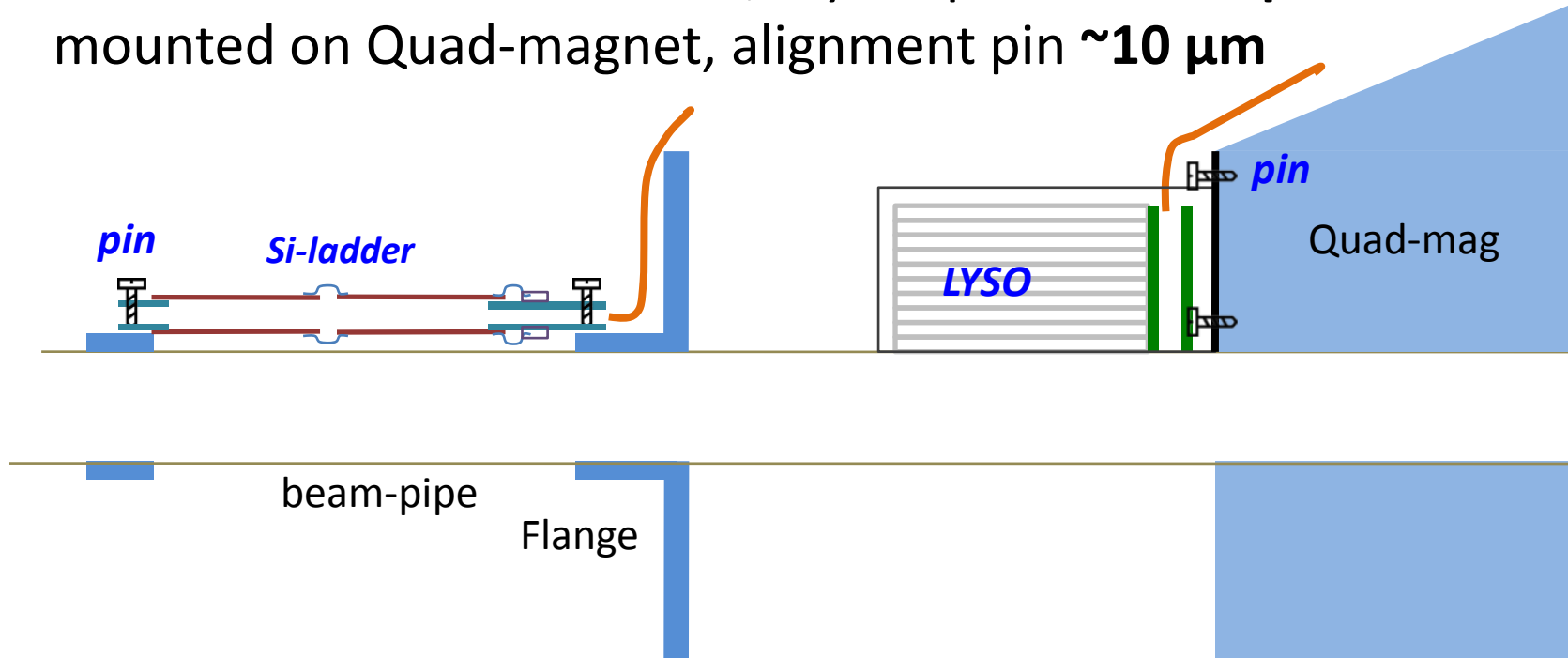
1st Si layer behind flange at $Z = 515$ mm

Octagon Si-ladders surrounding beampipe

1st layer $\sigma = 50$ μm

LumiCal assembly

- **Si-ladder** assembled on CNC table
alignment **pin/screw** to beam-pipe support
pin position precision $\sim 5 \mu\text{m}$
CNC survey of Si strip position $\sim 3 \mu\text{m}$
readout-hybrid heat dissipation \rightarrow flange water cooling
- **LYSO + SiPM** calorimeter
assembled in Steel container, crystal position $\sim 10 \mu\text{m}$
mounted on Quad-magnet, alignment pin $\sim 10 \mu\text{m}$



LumiCal Si-ladders: impact position

- **Bhabha electron theta resolution:**

$\delta L/L < 10^{-4} \rightarrow \delta\vartheta = 1.5 \mu\text{Rad}$ @fiducial edge $\theta_{\min} = 30 \text{ mRad}$

@ $Z = 0.5\text{m}$, $dr = 0.75 \mu\text{m}$; $dz = dr/\tan(.03) = \mathbf{25 \mu\text{m}}$

- **Si-ladders in z-phi 2-D assembly:**

z-strips for theta impact position: $< 200 \mu\text{m}$ pitch for resolution $< 25 \mu\text{m}$

phi-strips: $\sim 1 \text{ mm}$ pitch to correct boosted direction

- **Assembly precision:**

wafer on ladder module: CNC table glue/survey to $\mathbf{3 \mu\text{m}}$

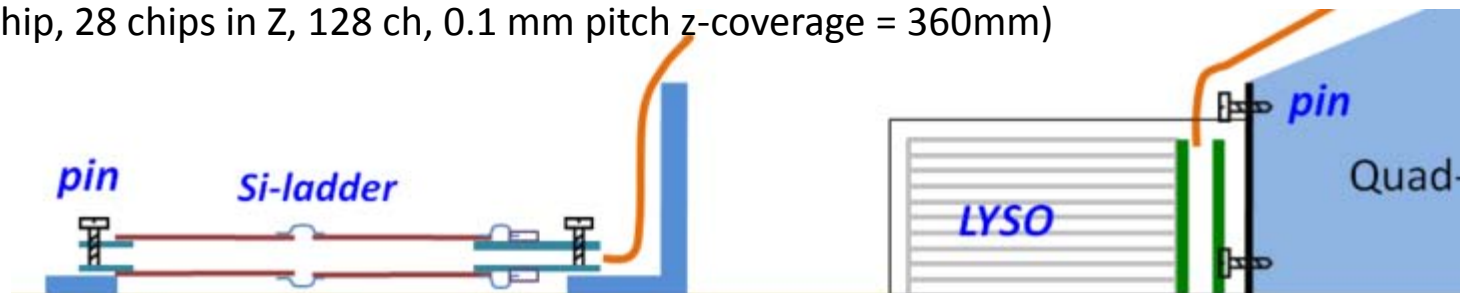
ladder on beam-pipe support: alignment pin to $\mathbf{10 \mu\text{m}}$ in Z

Beam-pipe over 1 m thermal/humidity \rightarrow deviation $\sim 5 \mu\text{m}$?

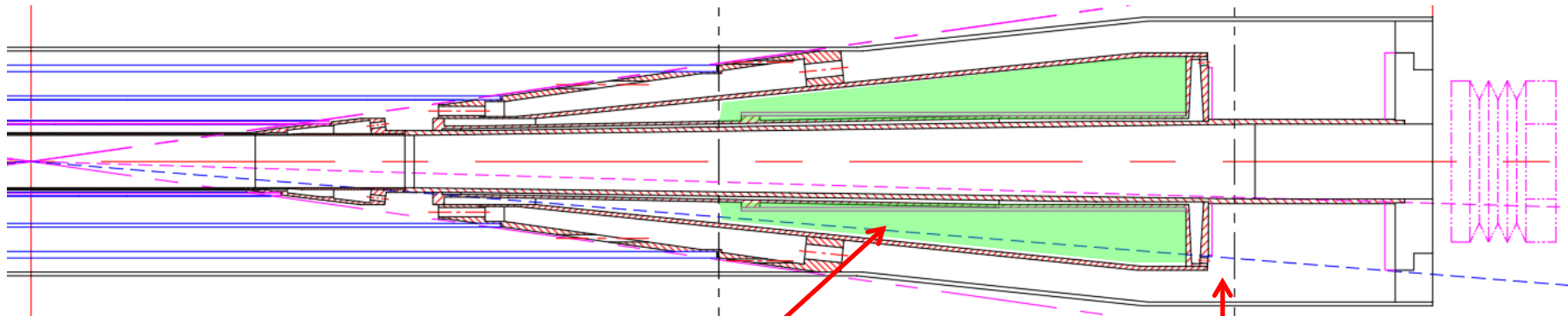
- **Heat dissipation:**

8 pairs of z-phi ladders, 30 chips $\rightarrow \mathbf{100 \text{ W /per z-side}}$

(APV25 0.4 W/chip, 28 chips in Z, 128 ch, 0.1 mm pitch z-coverage = 360mm)



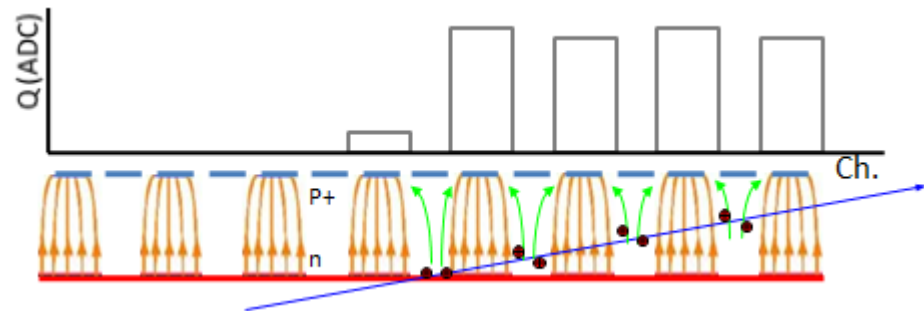
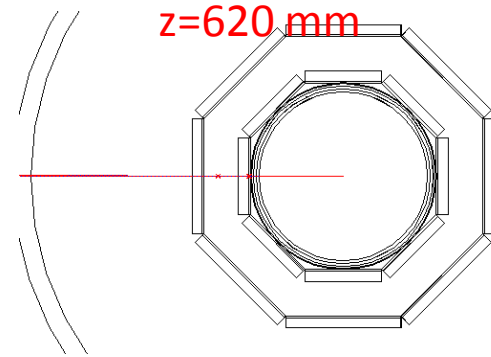
LumiCal Si-wafer option



- **LumiCal Si wafer volume**
round beampipe $\phi = 28 \text{ mm}$
 $\theta = 30 \text{ mRad @ } z = 500 \text{ mm}$
Multi. scattering $\sigma = 50 \mu\text{m}$

Assuming Si strip $300 \mu\text{m}$ thick, pitch = $100 \mu\text{m}$,
resolution by the fraction of entrance strip (low z)

- ➔ *fire 100 strips @ 30 mRad*
- ➔ *rather extreme for Si strip resolution by charge sharing at the edge strips*



LumiCal LYSO+SiPM calorimeter

- **Upstream materials:**

beam-pipe, flange → **~5 X0**

shower smearing → **shower center ~1 mm precision**

- **Pre-shower Si layer for e/γ ID :**

add Si-wafer: LYSO front is ~ shower-maximum position

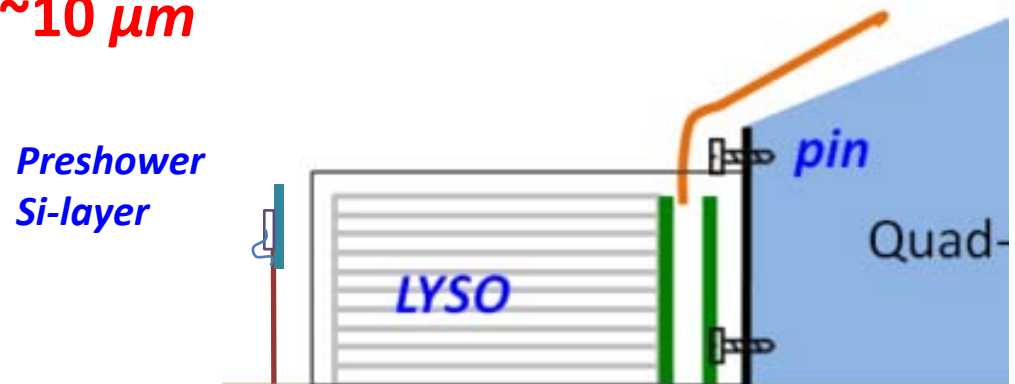
- **Readout of SiPM :**

is compact behind LYSO bars of 2x2 mm² surface

- **Assembly precision:**

LYSO ring ~50 kg, supported by alignment pins/screws, ~100 μm is sufficient

fabrication precision can reach ~10 μm



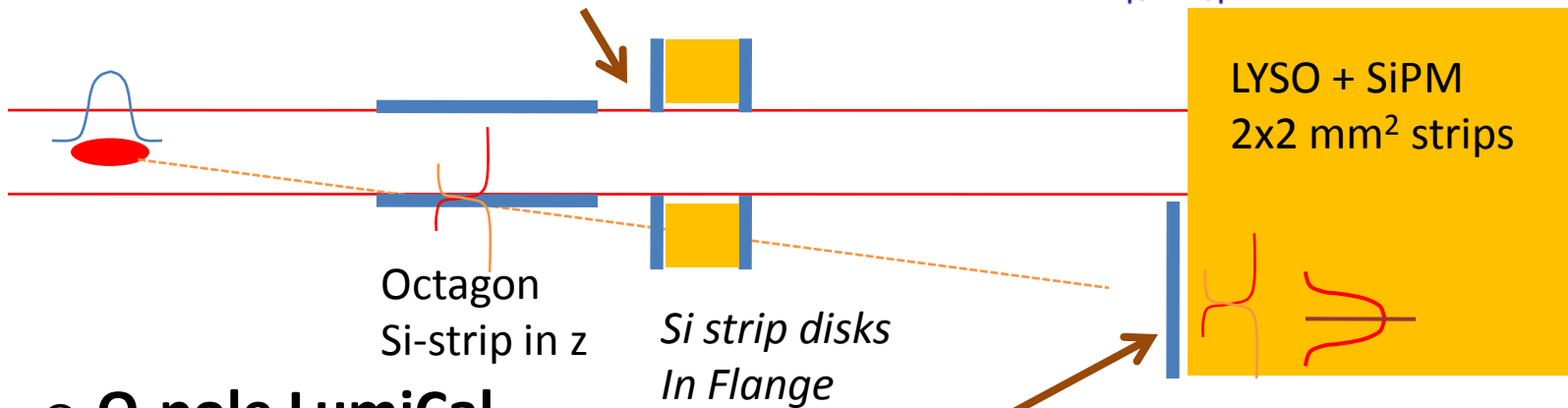
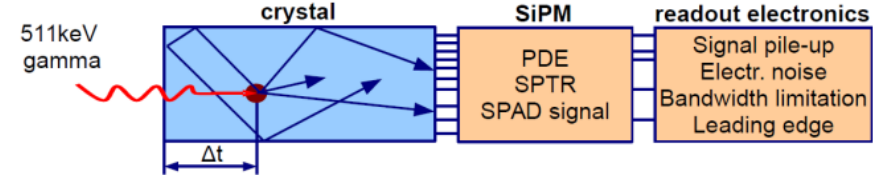
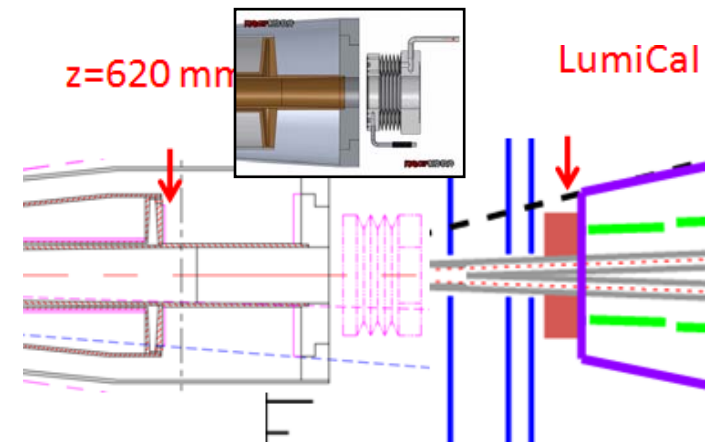
LumiCal Calo options

○ Calorimeter options

spatial resolution is not good
LYSO + SiPM is compact
minimize space for electronics

○ Flange/LYSO front

add Si-wafer as preshower
for e/ γ ID, NLO Bhabha etc

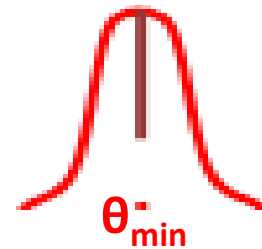


○ Q-pole LumiCal

100 mm long LYSO strips
for ID beam electron with EM shower

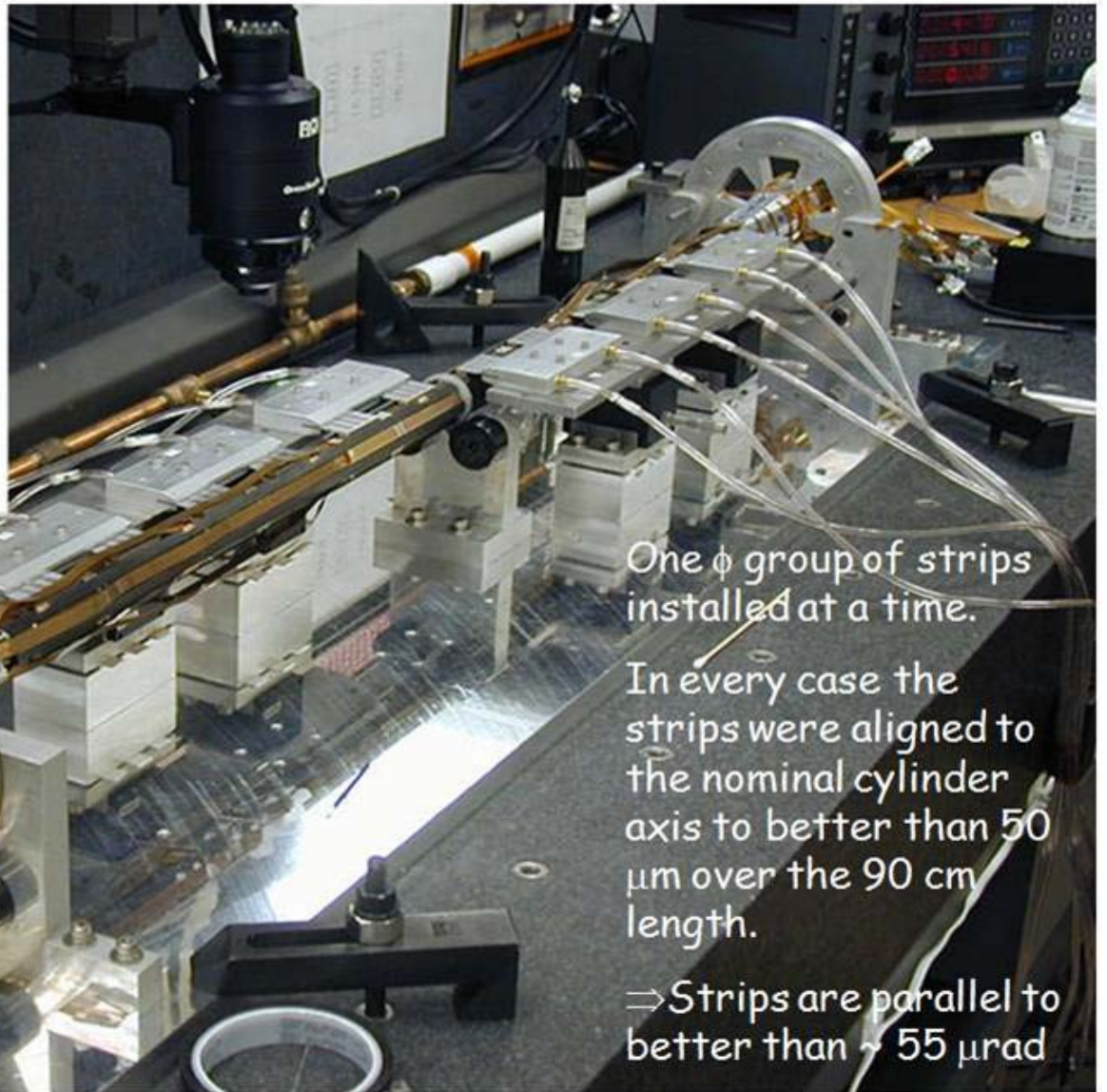
Summary

- Bhabha detection studied for luminosity precision
 $\delta L/L \sim 10^{-4}$
- With beampipe $\phi = 28 \text{ mm}$, $\vartheta_{min} \sim 30 \text{ mRad}$
Bhabha X-section matches to Z(qq) pole
- electron θ resolution at ϑ_{min} edge :
 $\delta L/L \sim 10^{-4} \rightarrow \sigma_{\vartheta_{min}} = 1.5 \mu\text{Rad}$
- **Si-ladders** surrounding beam-pipe :
 θ is measured in Z, $\sigma_{\vartheta_{min}} \rightarrow \sigma_z = 25 \mu\text{m}$
- Multiple-Scattering of beampipe RMS in Z = 50 μm
→ Si-ladders measure the MS profile
 $\sigma_{\theta_{min}}$ estimated for the measured MS profile
→ Si-ladder of 100 μm pitch in Z
 $\sigma_z^{\text{measured}}$ is expected for $\sim 10 \mu\text{m}$



*Backup
CDF tracker assembly*

CDF L00 assembly

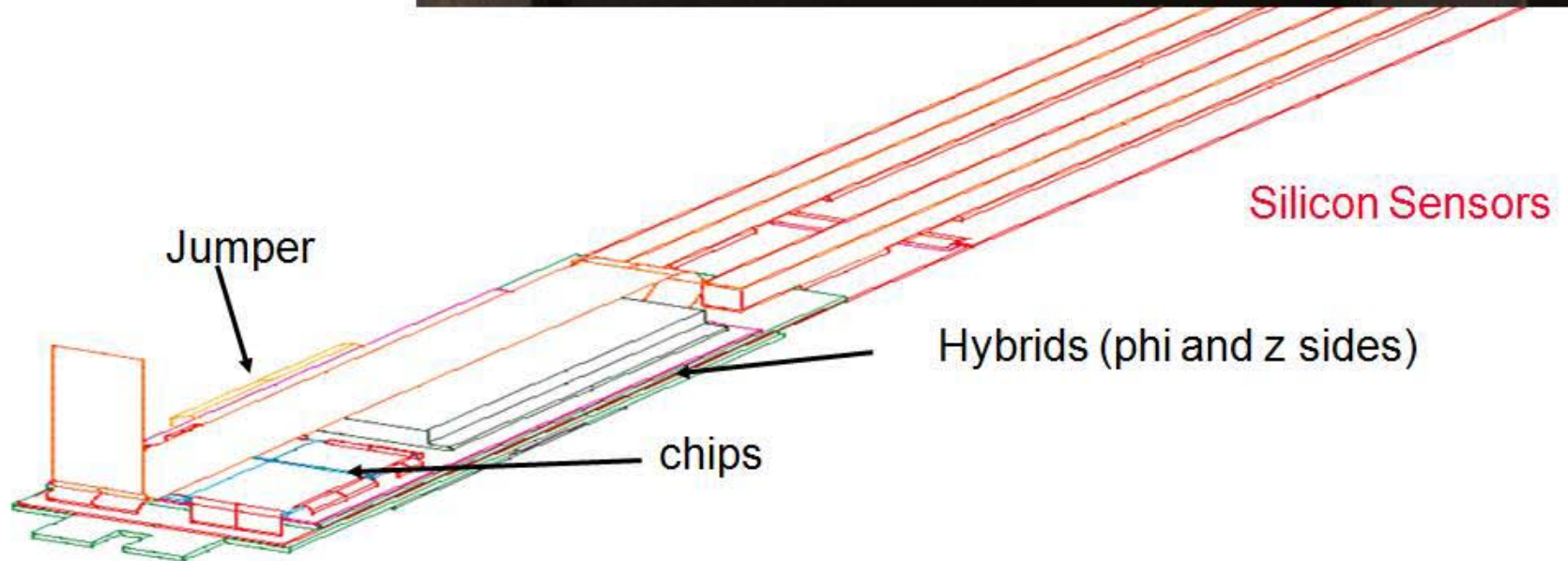
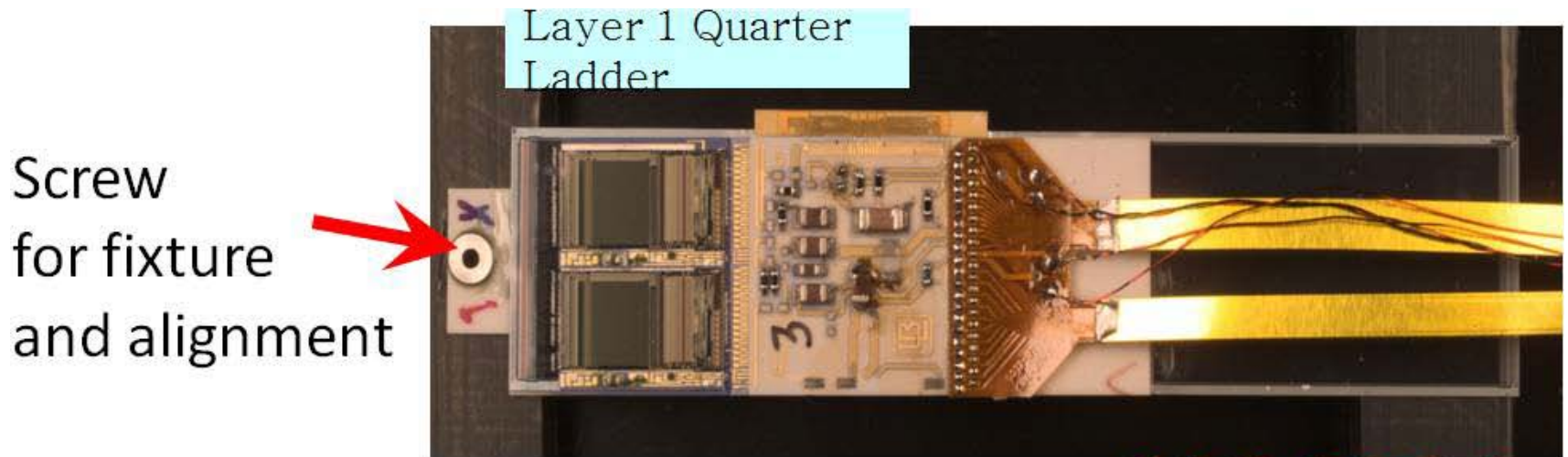


One ϕ group of strips installed at a time.

In every case the strips were aligned to the nominal cylinder axis to better than $50 \mu\text{m}$ over the 90 cm length.

\Rightarrow Strips are parallel to better than $\sim 55 \mu\text{rad}$

SVXII Assembly



Silicon Detector Installation

